

ATC-EHV SERIESElectron Beam Evaporation Systems



GENERAL INFORMATION

AJA International **ATC-E HV Series Electron Beam Evaporation Systems** are available in stainless steel, box-style chambers. These physical vapor deposition systems offer exceptional value while delivering optimal performance and utilizing top quality sub-components. They inherit many design features and common parts from the highly evolved ATC & Orion sputtering tools and can be outfitted with a single or multi-pocket rotary e-beam source, thermal evaporation sources, ion / plasma sources, Knudsen cells, low temperature evaporation cells for organic materials and thermal evaporation furnace sources. In addition, these systems are available with load-locks, QCM control, heated or cooled substrate holders with tilting capability, planetaries, various pumping packages and automated control.



SYSTEM FEATURES

- Accommodates Single Or Rotary Pocket Electron Beam Source
- Secondary Thermal Evaporation Sources
- Ion Source For Ion Assisted Deposition And Sample Pre-Cleaning
- Accommodates Up To 8" Diameter Substrates Or Small Batch Coatings ((3) 4" Wafers)
- Substrate Handling Capabilities Can Include: Heating, Cooling (LN2/H2O), Tilting, RF Biasing, Rotation And Z-Motion

- Single And Multi-Crystal Controllers Available
 For Single-Layer, Multi-Layer, And
 Co-Deposition Applications
- Turbo-Pumped Load-Lock Systems Available With Cassettes
- Base Vacuum (e10-7 to e10-8 Torr)
- Accommodates Up To (4) MFC Gas Lines
- Semi-Automatic Or LabVIEW Based Computer Control System

SUBSTRATE HOLDERS - HEATING / COOLING

AJA can fit your customized evaporation system with a wide variety of substrate holders. Our substrate heaters can be equipped with azimuthal rotation, heating up to 1000°C, RF/DC bias capability and tilting in a single axis plane. Our cooled stages can be equipped with H2O or LN2 cooling in the static or rotational modes. Additional features include azimuthal rotation, RF/DC bias and tilting in a single axis plane. Substrate holders can be semi-automatic or fully automated depending on the process requirements.

Custom configurations are also available when heating and cooling are required.

For batch coating applications domed-styled substrate carriers optimized for lift-off processing and planetary-style holders are also available. Process gas ring or gas distributor options are offered for reactive processing or applications requiring an anneal step.



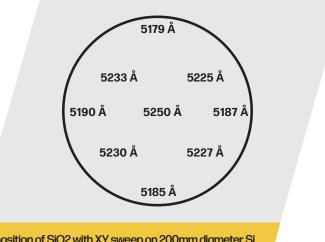
EVAPORATION SOURCES

AJA offers a variety of sources on our ATC-E Series Evaporation Systems. The box-style chambers are best suited for rotary e-beam sources which are bottom mounted with a large, double-hinged, easy access loading door for service and loading. Spare ports on the chamber bottom straddling the linear e-beam source allow for the addition of multiple secondary thermal evaporation sources. Secondary thermal sources are typically optimized for specific materials (e.g. organics) or to allow co-evaporation capabilities. With two or more evaporation sources, isolation shielding and individual shutters are included to minimize cross contamination.



TYPICAL RATE / UNIFORMITY DATA

The ATC-E Series Evaporation Systems can be configured for high rate, low rate, multi-layer and codeposition applications depending on the chamber, sources, substrate carrier and general configuration chosen. Proper power, crucible liner or boat material, soak, and XY sweep decisions must be made for each material to be evaporated to ensure the desired rates, stability and film characteristics. Typically, materials with good heat transfer properties (eg. Al) do not require XY sweep but may require a liner (Au) whereas materials with poor thermal properties (eg. Cr) tend to tunnel and spit unless the e-beam power is diffused with an XY sweep. Proper substrate fixturing is required to obtain the best uniformity.



Deposition of SiO2 with XY sweep on 200mm diameter Si wafer with simple, azimuthal rotation, run for 75 seconds at 8450V, 24 mA, 500 mm working distance.

Uniformity is +/- 0.7%.

SYSTEM OPTIONS





For questions, quotes and ordering information please contact us directly:

